



EV318285108

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. .... 09/905,320  
Confirmation No. .... 6172  
Filing Date ..... July 13, 2001  
Inventor ..... Cem Basceri et al.  
Assignee ..... Micron Technology, Inc.  
Group Art Unit ..... 1762  
Examiner ..... Eric B. Fuller  
Attorney's Docket No. .... MI22-1657  
Customer No. .... 021567  
Title: Chemical Vapor Deposition Methods of Forming Barium Strontium  
Titanate Comprising Dielectric Layers, Including Such Layers Having a  
Varied Concentration of Barium and Strontium Within the Layer

**RESPONSE TO JUNE 30, 2003 OFFICE ACTION**

To: Commissioner for Patents  
P. O. Box 1450  
Alexandria, VA 22313-1450

**VIA U.S. EXPRESS MAIL**

From: Mark Matkin (Tel. 509-624-4276; Fax 509-838-3424)  
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Responsive to the Office Action dated June 30, 2003, Applicant  
remarks as follows:

**AMENDMENTS**

**Amendments to the Claims**

None.